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Application No. <u>09921074</u>	Prepared by <u>ewc</u>	Tracking Number <u>05913639</u>	
Examiner-GAU <u>Easthorn</u>	Date <u>2-22-04</u>	Week Date <u>3-01-04</u>	
<u>2832</u>	No. of queries <u>-1-</u>	<u>IFW</u>	

JACKET			
a. Serial No.	f. Foreign Priority	k. Print Claim(s)	p. PTO-1449
b. Applicant(s)	g. Disclaimer	l. Print Fig.	q. PTOL-85b
c. Continuing Data	h. Microfiche Appendix	m. Searched Column	r. Abstract
d. PCT	i. Title	n. PTO-270/328	s. Sheets/Figs
e. Domestic Priority	j. Claims Allowed	o. PTO-892	t. Other

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Attorney Docket: GD7240US.CIP

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2-5

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

INFORMATION DISCLOSURE CITATION

In re application of: Jiangtao Wang et al.

Serial No: 09/921,074 Group No.: 3729
Filed: August 2, 2001 Examiner: Not yet known
For: RESISTOR COMPONENT WITH MULTIPLE LAYERS
OF RESISTIVE MATERIAL

Assistant Commissioner for Patents
Washington, DC 20231

U.S. Patent Documents

Examiner Initials	Document Number	Date	Name	Class
<u>ce</u>	2,662,957	12/15/1953	P. Eisler	201/73

Foreign Patent Documents

Examiner Initials	Document Number	Country	Class	Translation (Yes/No)
<u>ce</u>	690,691	England	36, 37 and 140	yes (4/1953)
<u>u</u>	EP 0 007 598	Europe	H 01 C 7/00	yes (2/1980)

Examiner:

Date Considered:

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